

2A, 600V N-CHANNEL MOSFET

GENERAL DESCRIPTION

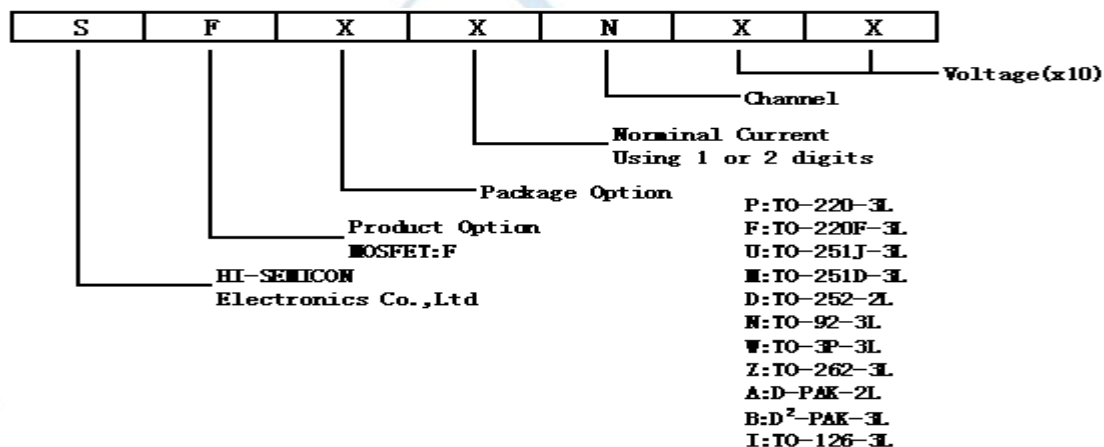
This power mosfet is an N-channel enhancement mode power MOS field effect transistor which is produced using Hi-semicon proprietary F-Cell™ structure VDMOS technology. The improved planar stripe cell and the improved guard ring terminal have been especially tailored to minimize on-state resistance, provide superior switching performance, and withstand high energy pulse in the avalanche and commutation mode.

These devices are widely used in AC-DC power suppliers, DC-DC converters and H-bridge PWM motor drivers.

FEATURES

- ◆ 2A, 600V, $R_{DS(on)}(typ.) = 3.7\Omega @ V_{GS} = 10V$
- ◆ 2Low gate charge
- ◆ 2Low C_{rss}
- ◆ 2Fast switching
- ◆ 2Improved dv/dt capability

NOMENCLATURE



ORDERING INFORMATION

Part No.	Package Type	Marking	Material	Packing
SFM2N60	TO-251D-3L	SFM2N60	Pb free	Tube
SFU2N60	TO-251J-3L	SFU2N60	Pb free	Tube
SFI2N60	TO-126-3L	SFI2N60	Pb free	Bulk
SFF2N60	TO-220F-3L	SFF2N60	Pb free	Tube
SFP2N60	TO-220-3L	SFP2N60	Pb free	Tube
SFD2N60	TO-252-2L	SFD2N60	Pb free	Tape & Reel

ABSOLUTE MAXIMUM RATINGS (T_C=25°C unless otherwise noted)

Characteristics		Symbol	Ratings					Unit
			SFM/D 2N60	SFU 2N60	SFI 2N60	SFP 2N60	SFF 2N60	
Drain-Source Voltage		V _{DS}	600					V
Gate-Source Voltage		V _{GS}	±30					V
Drain Current	T _C =25°C	I _D	2.0					A
	T _C =100°C		1.3					
Drain Current Pulsed		I _{DM}	8					A
Power Dissipation(T _C =25°C)		P _D	34	35	30	44	23	W
-Derate above 25°C			0.27	0.28	0.24	0.35	0.18	W/°C
Single Pulsed Avalanche Energy(Note 1)		E _{AS}	115					mJ
Operation Junction Temperature Range		T _J	-55~+150					°C
Storage Temperature Range		T _{sta}	-55~+150					°C

THERMAL CHARACTERISTICS

Characteristics	Symbol	Ratings					Unit
		SFM/D 2N60	SFU 2N60	SFI 2N60	SFP 2N60	SFF 2N60	
Thermal Resistance, Junction-to-Case	R _{θJC}	3.7	3.57	4.17	2.86	5.56	°C/W
Thermal Resistance, Junction-to-Ambient	R _{θJA}	110	110	62.5	62.5	120	°C/W

ELECTRICAL CHARACTERISTICS (T_C=25°C unless otherwise noted)

Characteristics	Symbol	Test conditions	Min.	Typ.	Max.	Unit
Drain -Source Breakdown Voltage	B _{VDS}	V _{GS} =0V, I _D =250μA	600	--	--	V
Drain-Source Leakage Current	I _{DSS}	V _{DS} =600V, V _{GS} =0V	--	--	1.0	μA
Gate-Source Leakage Current	I _{GSS}	V _{GS} =±30V, V _{DS} =0V	--	--	±100	nA
Gate Threshold Voltage	V _{GS(th)}	V _{GS} = V _{DS} , I _D =250μA	2.0	--	4.0	V
Static Drain- Source On State Resistance	R _{DS(on)}	V _{GS} =10V, I _D =1.0A	--	3.7	4.2	Ω
Input Capacitance	C _{iss}	V _{DS} =25V, V _{GS} =0V, f=1.0MHZ	--	250.1	--	pF
Output Capacitance	C _{oss}		--	35.7	--	
Reverse Transfer Capacitance	C _{rss}		--	1.1	--	
Turn-on Delay Time	t _{d(on)}	V _{DD} =300V, I _D =2.0A, R _G =25Ω (Note 2,3)	--	9.2	--	ns
Turn-on Rise Time	t _r		--	23.4	--	
Turn-off Delay Time	t _{d(off)}		--	15.3	--	
Turn-off Fall Time	t _f		--	20.1	--	
Total Gate Charge	Q _g	V _{DS} =480V, I _D =2.0A, V _{GS} =10V (Note 2,3)	--	5.67	--	nC
Gate-Source Charge	Q _{gs}		--	1.74	--	
Gate-Drain Charge	Q _{gd}		--	1.99	--	

SOURCE-DRAIN DIODE RATINGS AND CHARACTERISTICS

Characteristics	Symbol	Test conditions	Min.	Typ.	Max.	Unit
Continuous Source Current	I_S	Integral Reverse P-N Junction Diode in the MOSFET	--	--	2.0	A
Pulsed Source Current	I_{SM}		--	--	8.0	
Diode Forward Voltage	V_{SD}	$I_S=2.0A, V_{GS}=0V$	--	--	1.4	V
Reverse Recovery Time	T_{rr}	$I_S=2.0A, V_{GS}=0V,$ $dI_F/dt=100A/\mu S$	--	356.75	--	ns
Reverse Recovery Charge	Q_{rr}		--	1.03	--	μC

Notes:

1. $L=30mH, I_{AS}=2.52, V_{DD}=145V, R_G=25\Omega$, starting $T_J=25^\circ C$;
2. Pulse Test: Pulse width $\leq 300\mu s$, Duty cycles $\leq 2\%$;
3. Essentially independent of operating temperature.

TYPICAL CHARACTERISTICS

Figure 1. On-Region Characteristics

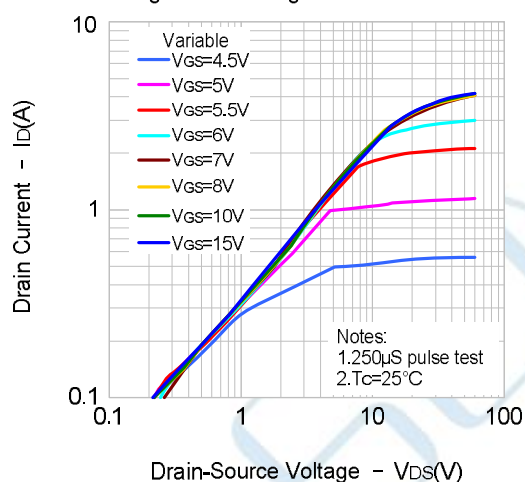


Figure 2. Transfer Characteristics

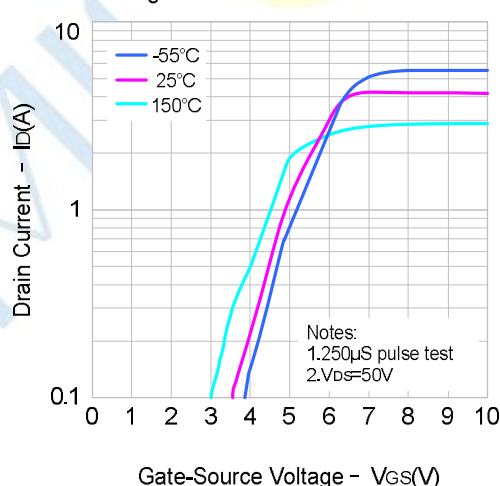


Figure 3. On-Resistance Variation vs. Drain Current and Gate Voltage

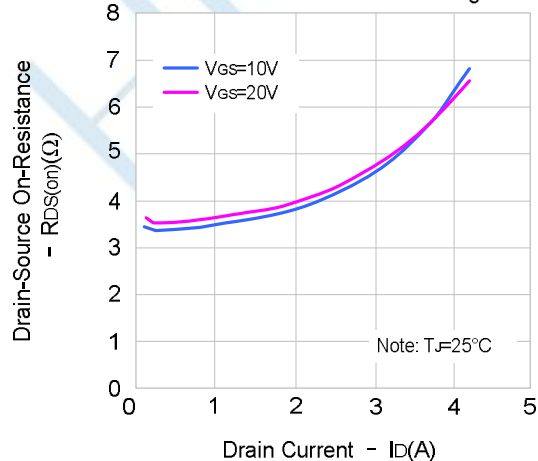
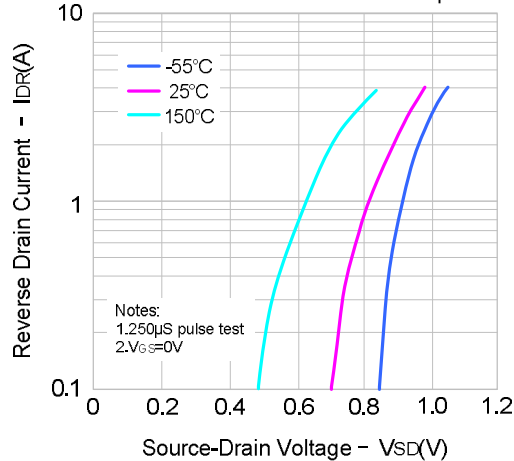


Figure 4. Body Diode Forward Voltage Variation vs. Source Current and Temperature



TYPICAL CHARACTERISTICS(CONTINUED)

Figure 5. Capacitance Characteristics

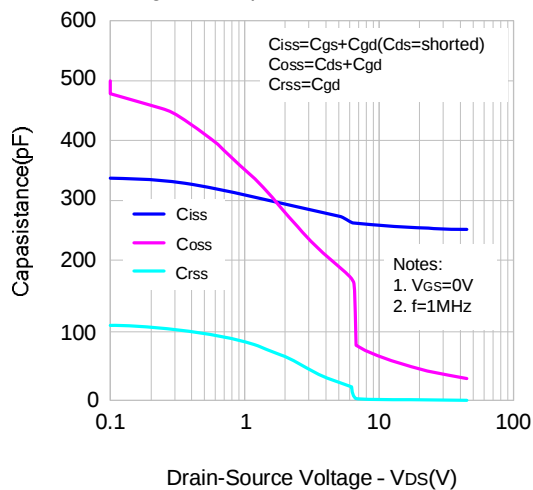


Figure 6. Gate Charge Characteristics

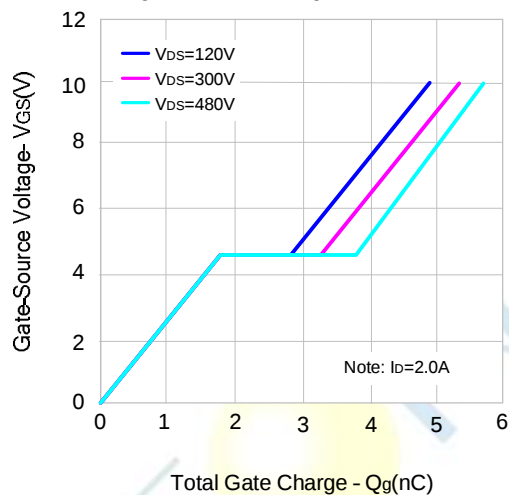


Figure 7. Breakdown Voltage Variation vs. Temperature

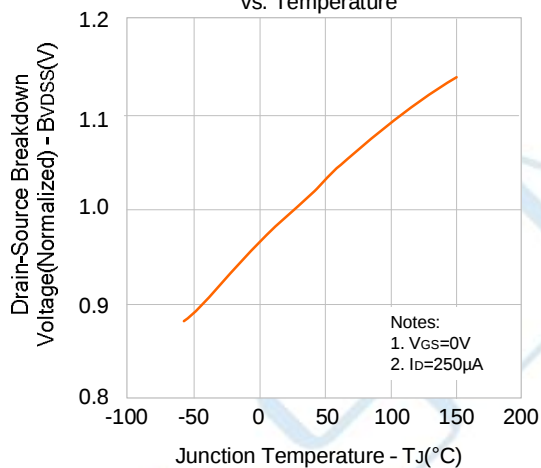


Figure 8. On-resistance Variation vs. Temperature

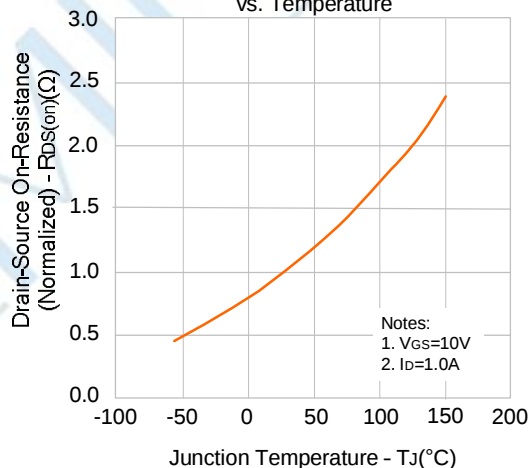


Figure 9-1. Max. Safe Operating Area (SFD/M2N60)

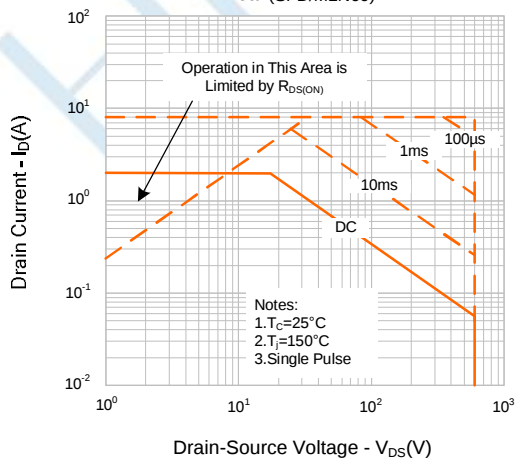
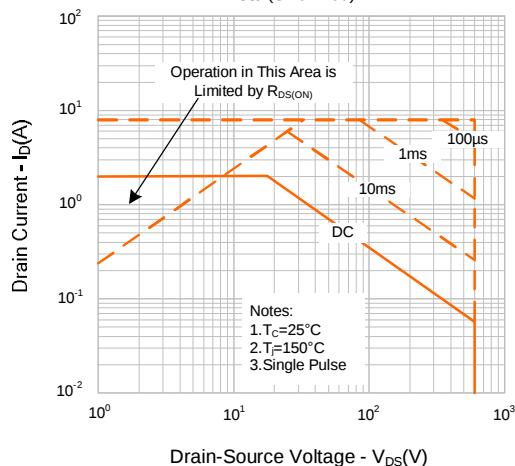


Figure 9-2. Max. Safe Operating Area (SFU2N60)



TYPICAL CHARACTERISTICS (CONTINUED)

Figure 9-3. Max. Safe Operating Area (SFP2N60)

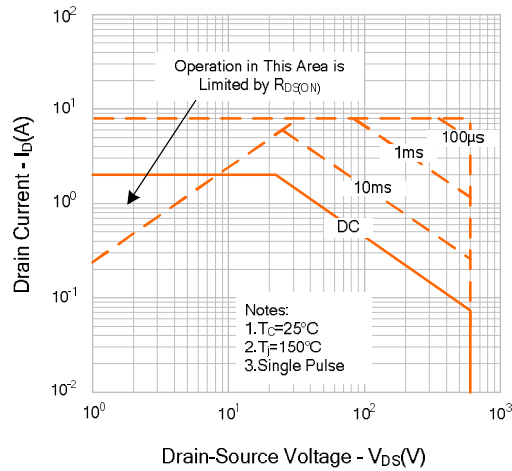


Figure 9-4. Max. Safe Operating Area (SFF2N60)

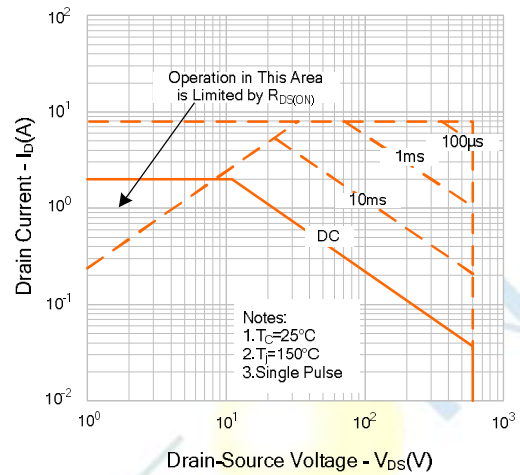


Figure 9-5. Max. Safe Operating Area (SFI2N60)

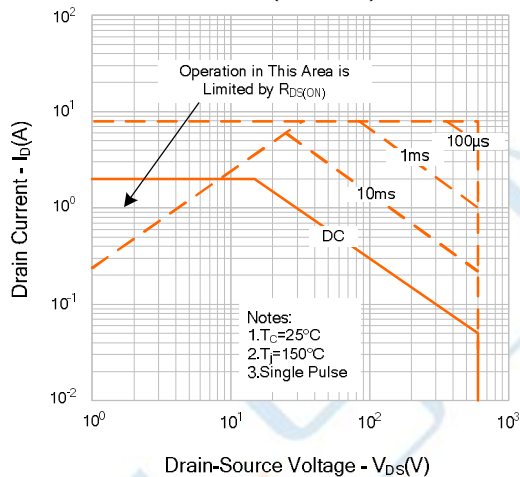
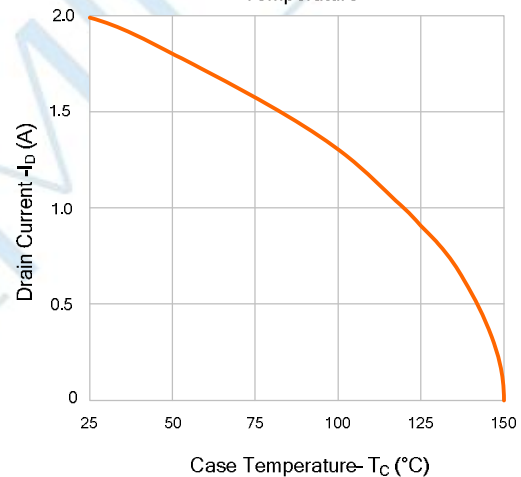
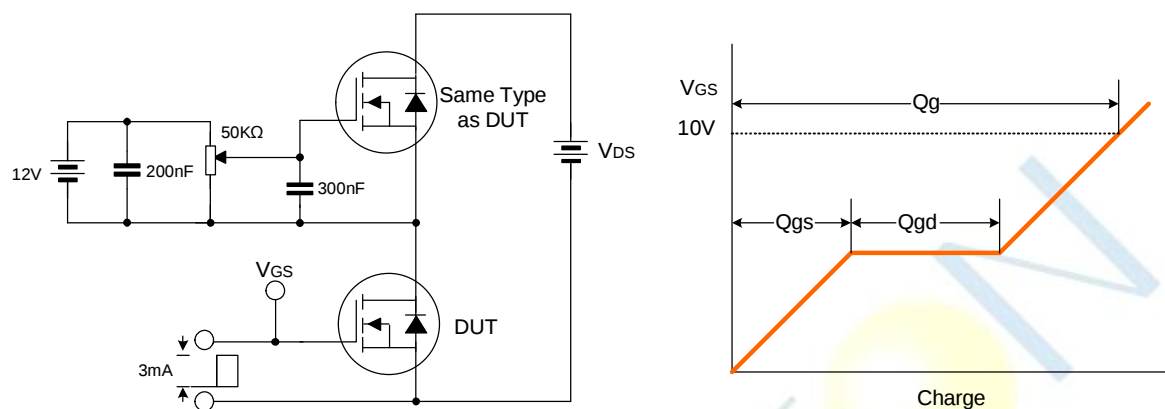


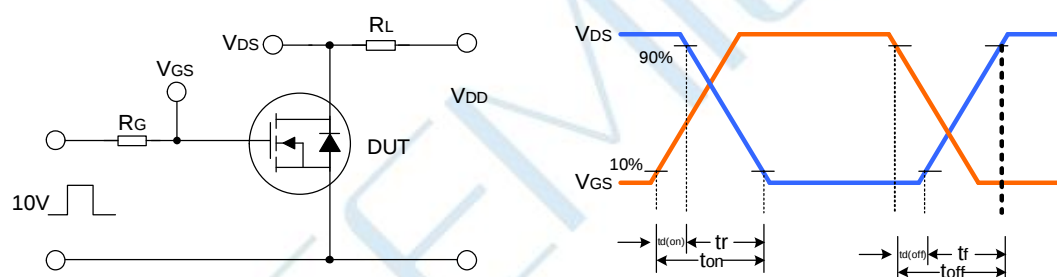
Figure 10. Max. Drain Current vs. Case Temperature



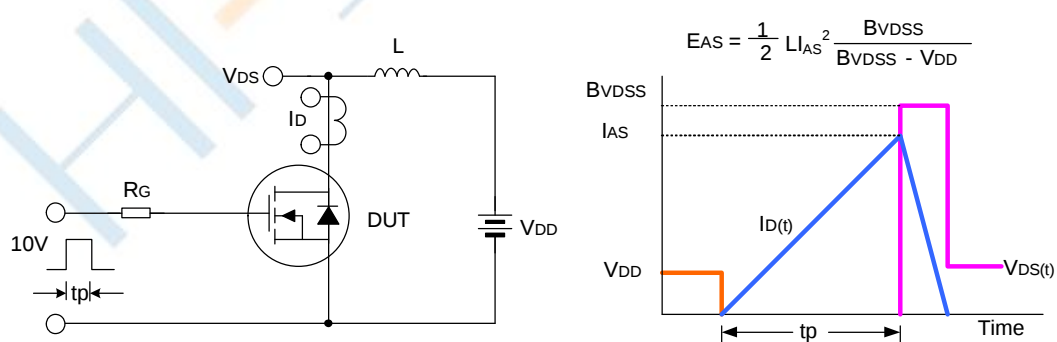
Gate Charge Test Circuit & Waveform



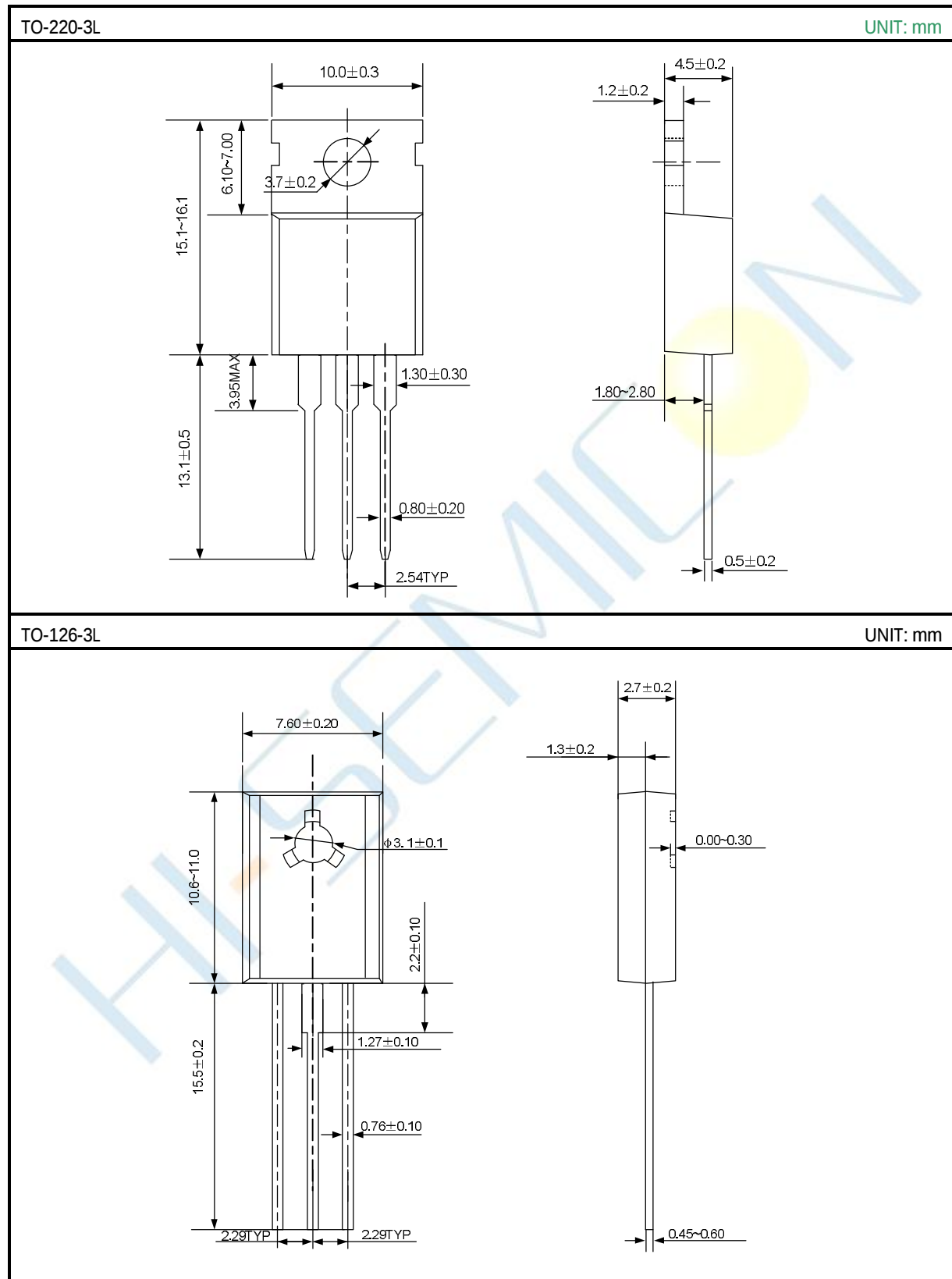
Resistive Switching Test Circuit & Waveform



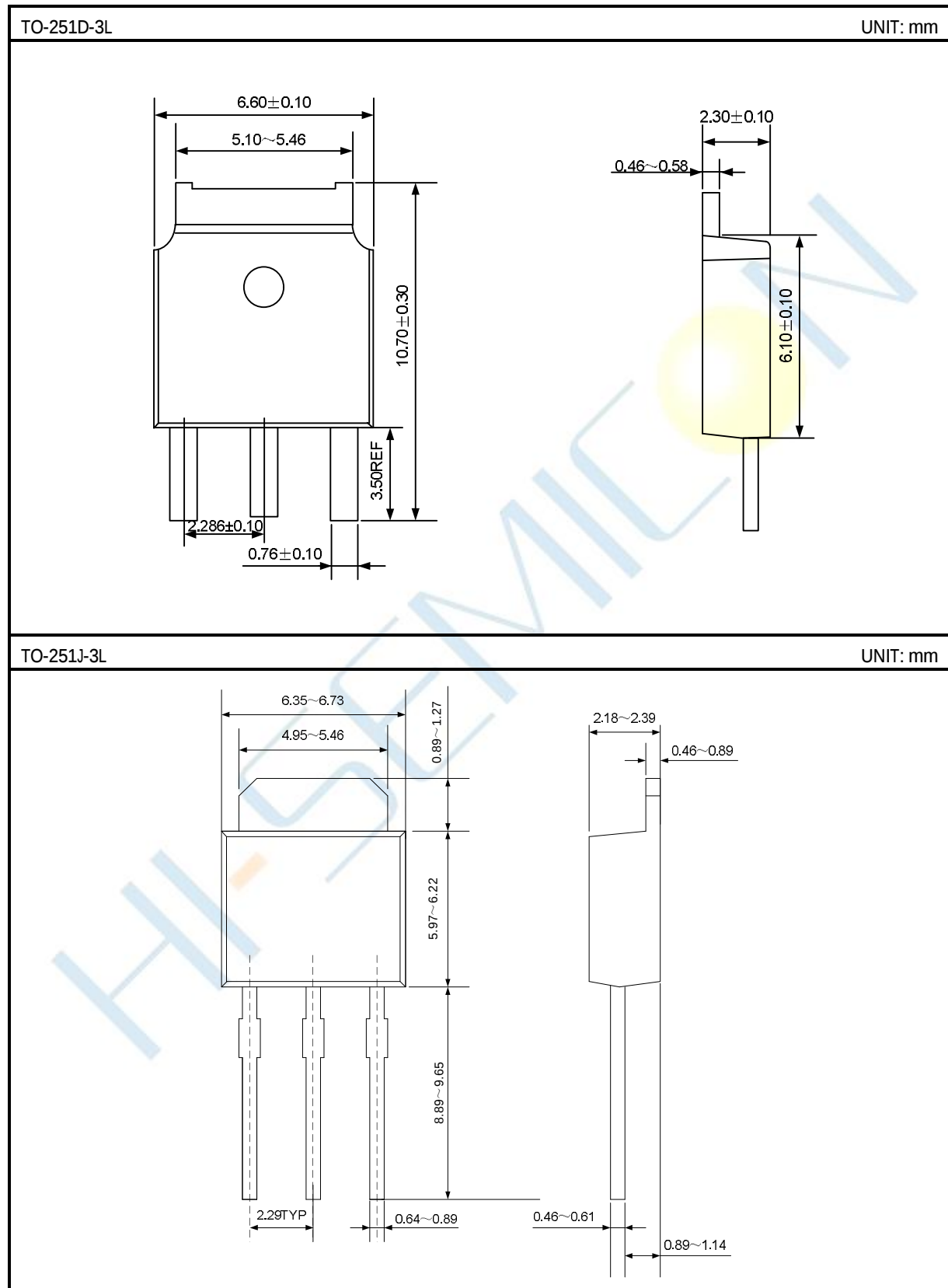
Unclamped Inductive Switching Test Circuit & Waveform



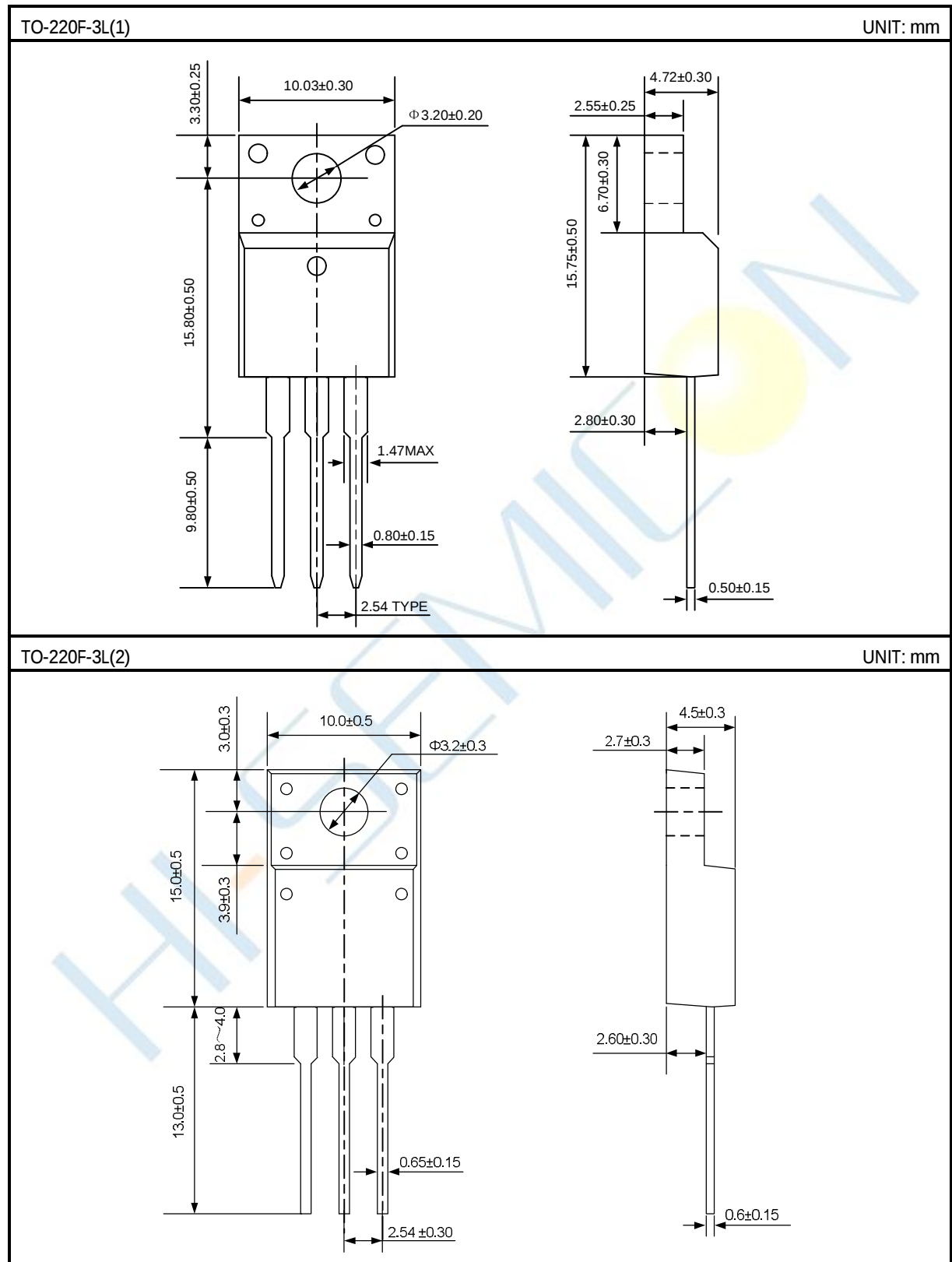
PACKAGE OUTLINE



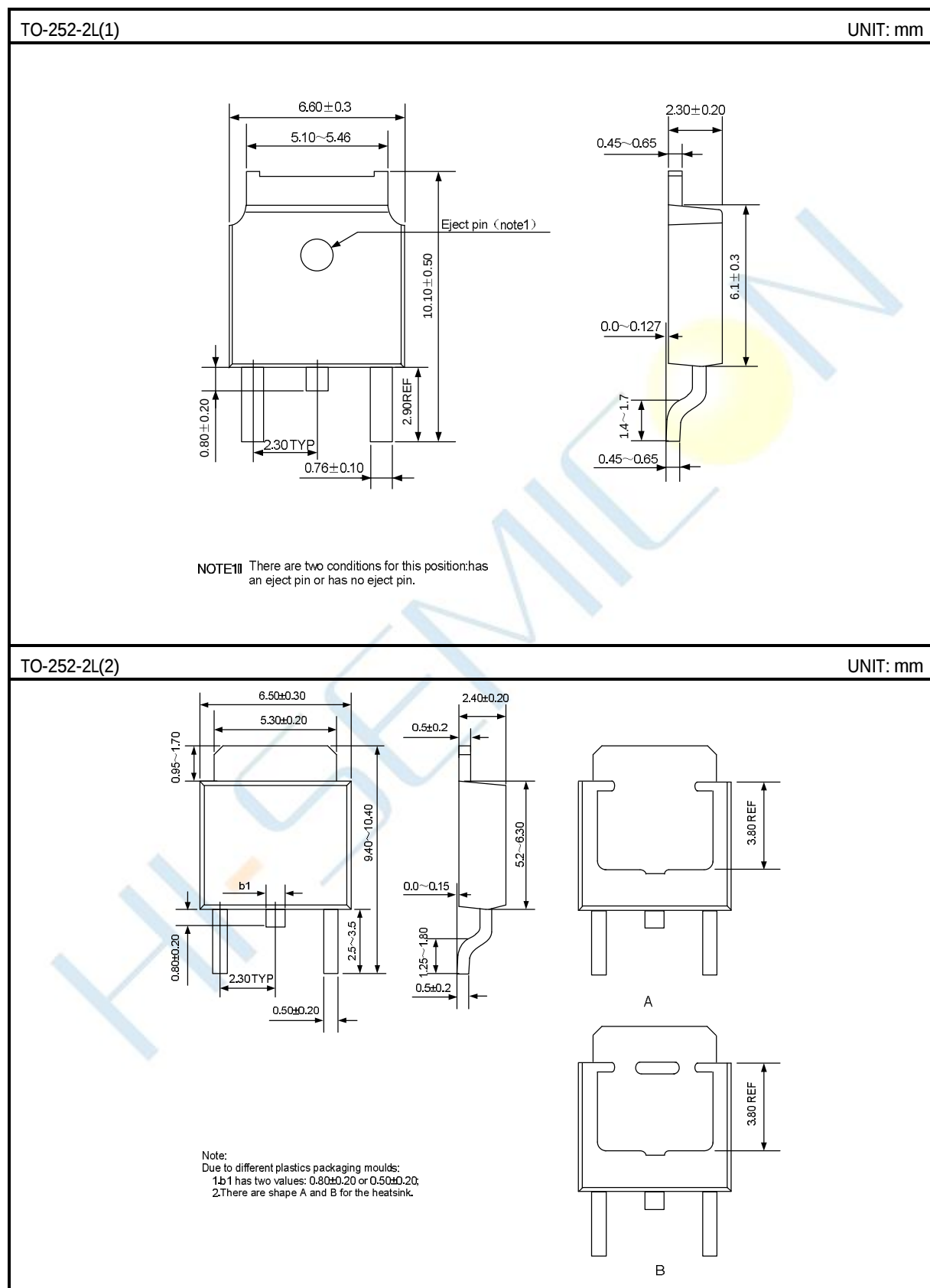
PACKAGE OUTLINE (continued)



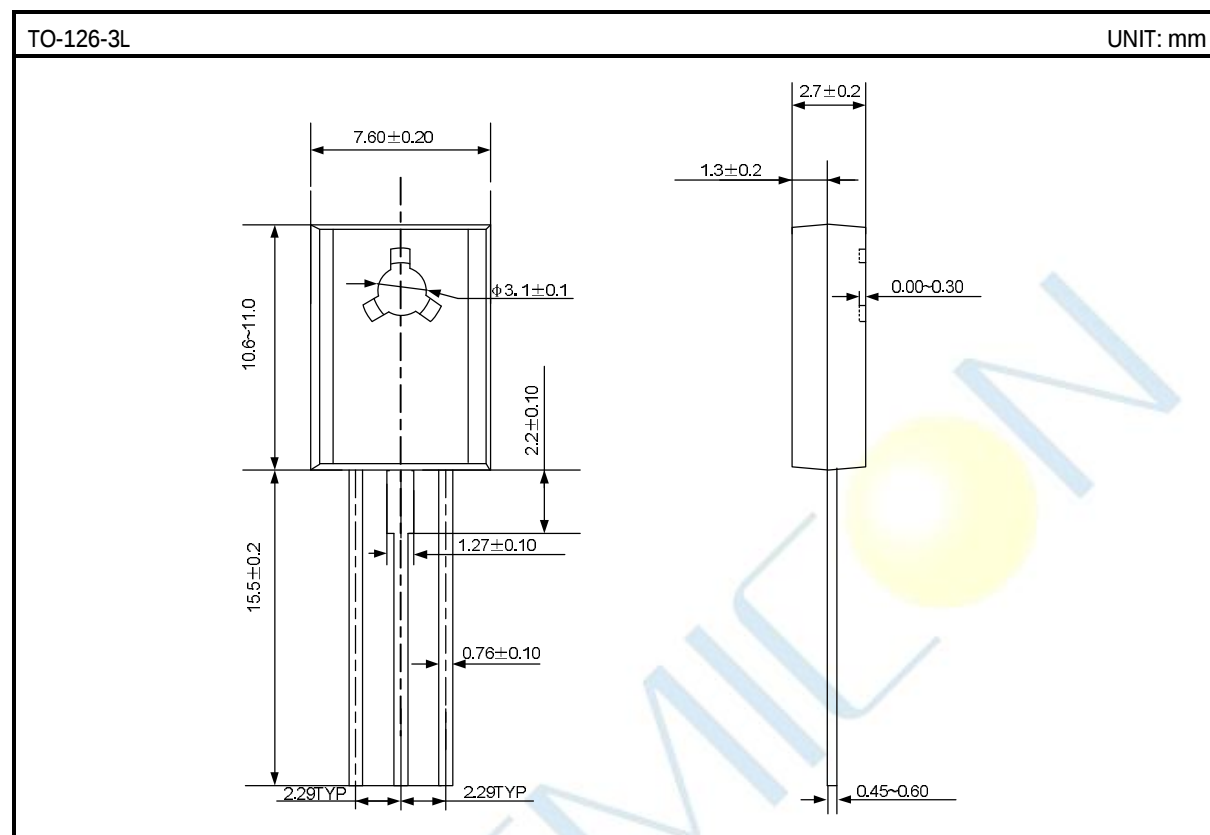
PACKAGE OUTLINE (continued)



PACKAGE OUTLINE (continued)



PACKAGE OUTLINE (continued)



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